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Plasma Medicine Technologies

Guest Editors:

Message from the Guest Editors

Prof. Dr. Eun Ha Choi

Dear Colleagues,

Prof. Dr. Nagendra Kumar Kaushik

Dr. Sander Bekeschus

Prof. Dr. Hiromasa Tanaka

Dr. Abraham Lin

Deadline for manuscript submissions:

closed (30 September 2020)

Plasma Medicine Technologies aims to cover all the latest outstanding developments of plasma bioscience and medicine. The objective of this Special Issue is to present some research underlying new therapeutic methods useful in medicine, dentistry, sterilization, and, in the current scenario, challenges and perspectives in biomedical sciences. This issue will focus on basic studies on the characterization of the bioplasma sources applicable to the living cells, especially to the human body and fundamental researches of mutual intreactions between the bioplasma and organic–inorganic, liquids and bio- or nanomaterials. The knowledge that has arisen from studies in the plasma medicine area may translate into new innovations to treat patients in daily clinics.

Prof. Dr. Eun Ha Choi Prof. Dr. Nagendra Kumar Kaushik Dr. Sanders Bekechus Prof. Dr. Hiromasha Tanaka Dr. Abraham Lin *Guest Editors*











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Editor-in-Chief

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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

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